

09/806852

U.S. UTILITY Patent Application

APPLICATION NO. 09/806852	CONT/PRIOR D F	CLASS 430	SUBCLASS 270	ART UNIT 1756 1752	EXAMINER LEE, S. J.
------------------------------	-------------------	--------------	-----------------	--------------------------	------------------------

Tatsuro Nagahara  
Hideki Matsuo  
Tomoko Aoki  
Kazuhiro Yamada

Photosensitive polysilazane composition and method of forming patterned polysilazane film

PTO-2040  
12/89Continued on Issue Slip Inside File Jacket

**WARNING:**

**WARNING:** The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368. Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.

FILED WITH: ☐ DISK (CRF) ☐ FICHE ☒ CD-ROM  
(Attached in pocket on right inside flap)

(FACE)